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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/732,734	12/10/2003	Ilya Rushkin	339.7755USU	6685	
7590 06/09/2004			EXAMINER		
Paul D. Greel		LEE, SIN J			
Ohlandt, Greeley, Ruggiero & Perle, L.L.P. 10th Floor			ART UNIT	PAPER NUMBER	
One Landmark		1752			
Stamford, CT	06901-2682		DATE MAILED: 06/09/2004	1	

Please find below and/or attached an Office communication concerning this application or proceeding.

				A			
•	Applica	ation No.	Applicant(s)	r			
	10/732	,734	RUSHKIN ET AL.				
Office Action Summar	Y Examir	ner	Art Unit				
	Sin J. L	ee	1752				
The MAILING DATE of this con Period for Reply	nmunication appears on	the cover sheet wi	th the correspondence address	;			
A SHORTENED STATUTORY PERIOD THE MAILING DATE OF THIS COMMON - Extensions of time may be available under the property of the period for reply specified above is less than the seriod for reply is specified above, the maxing - Failure to reply within the set or extended period for Any reply received by the Office later than three meanned patent term adjustment. See 37 CFR 1.70.	MUNICATION. visions of 37 CFR 1.136(a). In no s communication. hirty (30) days, a reply within the s num statutory period will apply and or reply will, by statute, cause the s onths after the mailing date of this	event, however, may a nestatutory minimum of thirth will expire SIX (6) MON application to become AB	eply be timely filed y (30) days will be considered timely. THS from the mailing date of this communications.	cation.			
Status							
1) Responsive to communication(s	s) filed on <u>10 December</u>	<u>2003</u> .					
2a) ☐ This action is FINAL .							
	3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
closed in accordance with the p	ractice under Ex parte	Quayle, 1935 C.D	. 11, 453 O.G. 213.				
Disposition of Claims							
4)⊠ Claim(s) <u>1-36</u> is/are pending in	the application.						
4a) Of the above claim(s) is/are withdrawn from consideration.							
5) Claim(s) is/are allowed.							
6)⊠ Claim(s) <u>1-36</u> is/are rejected.							
7) Claim(s) is/are objected to.							
8) Claim(s) are subject to re	estriction and/or election	requirement.					
Application Papers							
9)☐ The specification is objected to t	ov the Examiner						
		b) objected to b	by the Examiner				
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner. Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).							
11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
Priority under 35 U.S.C. § 119	•						
_							
12) Acknowledgment is made of a c		ınder 35 U.S.C. §	119(a)-(d) or (f).				
a) ☐ All b) ☐ Some * c) ☐ None							
1. ☐ Certified copies of the pri							
 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this National Stage 							
			received in this National Stage	:			
application from the Interi * See the attached detailed Office	•	` ''					
Occure attached detailed Office a	action for a list of the ce	ranea cobies 110f f	CCCIVEU.	:			
Attachment(s)							
1) Notice of References Cited (PTO-892)		4) Interview Si	ummary (PTO-413)				
2) Notice of Draftsperson's Patent Drawing Revi		Paper No(s)	/Mail Date				
Information Disclosure Statement(s) (PTO-14 Paper No(s)/Mail Date	49 or PTO/SB/08)	5) Notice of In:	formal Patent Application (PTO-152)	į			
U.S. Patent and Trademark Office		5,	- ·				
PTOL-326 (Rev. 1-04)	Office Action Summ	nary	Part of Paper No./Mail Date 0604	42004			

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DETAILED ACTION

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1-12, 14, 17, 18-29, 31, and 34-36 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yamashiki et al (6,455,208 B1) in view of Matsuoka et al (5,397,682).

Yamashiki teaches (col.1, lines 40-43) a colored polymer thin film composed of a polymer such as a polyimide, and in his Production Example 3, Yamashiki obtains a 20% polyamic acid solution which contains solvents of *γ-butyrolactone* and N-methyl-2-pyrrolidone by reacting compounds including 4,4'-diaminodiphenyl ether (DAE) and 4,4'-oxydipththalic dianhydride (OPDA). The DAE is the present 4,4'-dimainodiphenyl ether of claims 3 and 5-7, and the OPDA is the present 3,3',4,4'-diphenyloxidetetracarboyxlic acid dianhydride of claims 3, 4 (see structure XV), 6, and 7. Therefore, Yamashiki also teaches present polyamic acid of the formula X of present claim 2.

Although Yamashiki does not explicitly teach the use of an adhesion promoter in his invention, it is well known in the art to add an adhesion promoter to a polyimide precursor composition in order to improve an adhesion property of the polyimide coating film to a substrate as evidenced by Matsuoka et al, col.11, lines 21-40. Matsuoka includes γ -glycidoxypropymethyldimethoxysilane (which meets present formula IV of

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present claim 1) as one of the examples for such adhesion promoting compounds. Based on Matsuoka's teaching, it would have been obvious to one of ordinary skill in the art to add an adhesion promoter such as γ -glycidoxypropylmethyldimethoxysilane into Yamashiki's polyamic solution so as to improve an adhesion property of his polyimide film to a substrate as taught by Matsuoka. Therefore, Yamashiki in view of Matsuoka would render obvious present inventions of claims 1-7, 9-11, and 14 (since Yamashiki teaches present polyamic acid of claims 2-7, it is the Examiner's position that Yamashiki's polyamic acid would inherently be soluble in aqueous tetramethylammonium hydroxide and would also inherently be resistant to a solvent used in a photosensitive composition with which the polyimide precursor composition is to be used as presently recited in claim 1).

With respect to present claim 8, in his Production Example 3, Yamashiki uses total of 1 mol of diamine compounds (DAE, PDA and SiDA) and 0.9975 mols of OPDA (a dianhydride compound). Therefore, Yamashiki in view of Matsuoka would render obvious present invention of claim 8.

With respect to present claim 12, in Production Example 3, Yamashiki uses solvents of *p-butyrolactone* and N-methyl-2-pyrrolidone. In col.15, lines 7-14, Yamashiki teaches that an organic solvent which does not dissolve the polyimide precursor by itself, for examples, ethanol, butanol, isopropanol, methyl cellosolve, ethyl cellosolve, or propyleneglycol monomethyl ether, can be mixed with the solvent which dissolves the polyimide precursor. Therefore, it would have been obvious to one of ordinary skill in the art to use propyleneglycol monomethyl ether (which has boiling point of 118-119°C)

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as the other solvent in Yamashiki's Production Example 3 with a reasonable expectation of obtaining a liquid crystal display exhibiting excellent display performance. Therefore, Yamashiki in view of Matsuoka would render obvious present invention of claim 12.

With respect to present claim 17, Matsuoka teaches that the amount of the adhesion promoter is preferably 0.5-10 parts by weight per 100 parts by weight of the polyimide precursor. The range overlaps with present range of claim 17 and thus would render the present range *prima facie* obvious. In the case "where the [claimed] ranges overlap or lie inside ranges disclosed by the prior art," a *prima facie* case of obviousness would exist which may be overcome by a showing of unexpected results, In re Wertheim, 541 F.2d 257, 191 USPQ 90 (CCPA 1976). Therefore, Yamashiki in view of Matsuoka would render obvious present invention of claim 17.

In col.6, lines 26-56, Yamashiki teaches that a color paste made of his polyamic solution is coated on the substrate and then heat-dried (Preferably at 80-120°C) to form a polyimide precursor colored film, Then a positive photoresist is coated on the polyimide precursor colored film to form a photoresist coating. Then, a mask is place on the photoresist coating, followed by irradiation with UV rays by using an exposure device. After exposure, the photoresist coating and the polyimide precursor colored film are simultaneously etched with a positive photoresist alkali developing solution. After etching, the unnecessary photoresist coating is separated. The polyimide precursor colored film is then converted to a polyimide colored film by heat treatment, preferably at 200-320°C. Therefore, Yamashiki in view of Matsuoka would render obvious present inventions of claims 18-29, 31, and 34-36.

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3. Claims 13 and 30 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yamashiki et al (6,455,208 B1) in view of Matsuoka et al (5,397,682) as applied to claims 12 and 29 above, and further in view of Durham et al (5,876,897).

Yamashiki et al in view of Matsuoka et al is discussed above in Paragraph 2. As discussed above, Yamashiki teaches the use of propyleneglycol monomethyl ether as the co-solvent that can be used together with his solvent that dissolves the polyimide precursor. The propyleneglycol monomethyl ether and 2-heptanone are well known in the art as equivalent organic solvents as evidenced by Durham et al, col.6, lines 47-58. Therefore, one of ordinary skill in the art would have found it obvious to use 2-heptanone as the other solvent in Yamashika's invention because propyleneglycol monomethyl ether and 2-heptanone were art-recognized equivalent organic solvents at the time the invention was made. Therefore, Yamashiki in view of Matsuoka and further in view of Durham would render obvious present inventions of claims 13 and 30.

4. Claims 15, 16, 32, and 33 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yamashiki et al (6,455,208 B1) in view of Matsuoka et al (5,397,682) as applied to claims 1 and 18 above, and further in view of Mahdi et al (US 2002/0100550 A1).

Yamashiki et al in view of Matsuoka et al is discussed above in Paragraph 2. As discussed above, Yamashiki in view of Matsuoka would render obvious adding an adhesion promoter to a polyimide precursor composition so as to improve an adhesion property of the polyimide coating film to a substrate. Matsuoka includes 3-methacryloxypropytrimethoxysilane as one of the examples for such adhesion

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promoting compounds, and Mahdi et al (see [0088]) teaches the equivalence of that compound and phenylaminopropytrimethoxysilane (which is the present adhesion promoter of formula I of claims 15 and 32 as well as the present adhesion promoter of formula XVII of claims 16 and 33) as adhesion-promoters. Since those two compounds were art-recognized equivalents (as adhesion-promoting compounds) at the time the invention was made, one of ordinary skill in the art would have found it obvious to add phenylaminopropytrimethoxysilane as the adhesion promoter in Yamashiki's polyamic acid solution with a reasonable expectation of improving an adhesion property of the polyimide coating film to a substrate. Therefore, Yamashiki in view of Matsuoka and further in view of Mahdi would render obvious present inventions of claims 15, 16, 32, and 33.

5. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Sin J. Lee whose telephone number is 571-272-1333. The examiner can normally be reached on Monday-Friday from 9:00 am EST to 5:30 pm EST.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Mark F. Huff, can be reached on 571-272-1385. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR.

Status information for unpublished applications is available through Private PAIR only.

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S.J.L.

S. Lee

June 4, 2004

Sin J. Lee

Sin J. Lee Patent Exammer

Technology Center 1700